# ATIONAL TECHNOLOGY ABORATORY

Ab initio study of diffusivity and ionic conductivity of  $Ln_2NiO_{4+\delta}(Ln=La, Nd, Pr)$  mixed conductor Songge Yang<sup>1</sup>, Guangchen Liu<sup>1</sup>, Yueh-Lin Lee<sup>2</sup> Yu Zhong<sup>1</sup>



<sup>1</sup>Department of Mechanical and Material Engineering, Worcester Polytechnic Institute, 100 Institute Rd, Worcester, MA, 01609, USA

<sup>2</sup>National Energy Technology Laboratory, 626 Cochrans Mill Road, P.O. Box 10940, Pittsburgh, Pennsylvania 15236-0940, USA







# **Objective of the work**



#### **Action items:**

- Calculations of the Vacancy formation energy
- Calculations of the thermal expansion coefficient
- Extrapolation of the temperature-dependent energy barrier
- Prediction of the diffusion coefficient and ionic conductivity ( $Ln_2NiO_{4+\delta}$ ,  $\delta=0.125$ )

# Equation of state of Ln<sub>2</sub>NiO<sub>4</sub> (Ln=La, Nd, Pr)



# **Temperature-dependent properties-Ln<sub>2</sub>NiO<sub>4+δ</sub>**



# **Oxygen migration path** $(Ln_2NiO_{4+\delta})$



# Volume thermal expansion of $Ln_2NiO_4$ (Ln=La, Nd, Pr)



# **Comparison with exp:**



### **Computational details**

#### Ab initio calculations:

- Vienna ab initio simulation package (VASP)
- Generalized gradient approximation (GGA) with the Perdew-Burke-Ernzerhof (PBE) exchange-
- correlation functional
- □ Monkhorst-Pack k-point meshes with density not less than 5000 pra (per-reciprocal-atom))
- The DFT+U approach was adopted in the present work
  - ◆ d-element Ni: U=6 eV (adopted the value from Staykov et al. )
- ◆ f-element Nd: U=6 eV (fitted the EDOS result produced by HSE06 function), Pr=3 eV
  - (adopted the value from Staykov et al.)

Ref. Staykov, A., Nguyen, T., Akbay, T. and Ishihara, T., 2022. Oxygen Reduction Reaction and Electronic Properties of LnO-Terminated Surfaces of Pr2NiO4 and La2NiO4. *The Journal* of Physical Chemistry C, 126(17), pp.7390-7399.



# **Selected diffusion paths**







## **Comparison between different A-site elements**



# Conclusions

- The vacancy diffusion might not play a dominant role for the Ln2NiO4 materials due to the high vacancy formation energy.
- After the investigation of different possible pathways, it can be concluded that the interstitial  $O^{2-}$  of the  $Ln_2NiO_{4+\delta}$  should
- migrate parallel to the ab plane instead of the c direction, as the energy barrier along the ab plane is lower.
- The ranking of the diffusion coefficient and ionic conductivity of  $Ln2NiO_{4+\delta}$ , from the highest to the lowest, is  $Pr2NiO_{4+\delta}$ ,



### Acknowledgments

• Thanks for the funding support from Department of Energy-National Energy Technology Laboratory(DOE-NETL): DE-

#### FE0031972

• Thanks for the help from the program manager: Sarah Michalik

• Thanks for the collaboration with Dr. Yueh-lin Lee